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Initial Results of the ECR Charge Breeder for the ^{252}Cf Fission Source Project at ATLAS

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U.S. Department
of Energy



A U.S. Department of Energy laboratory
managed by The University of Chicago

Overview

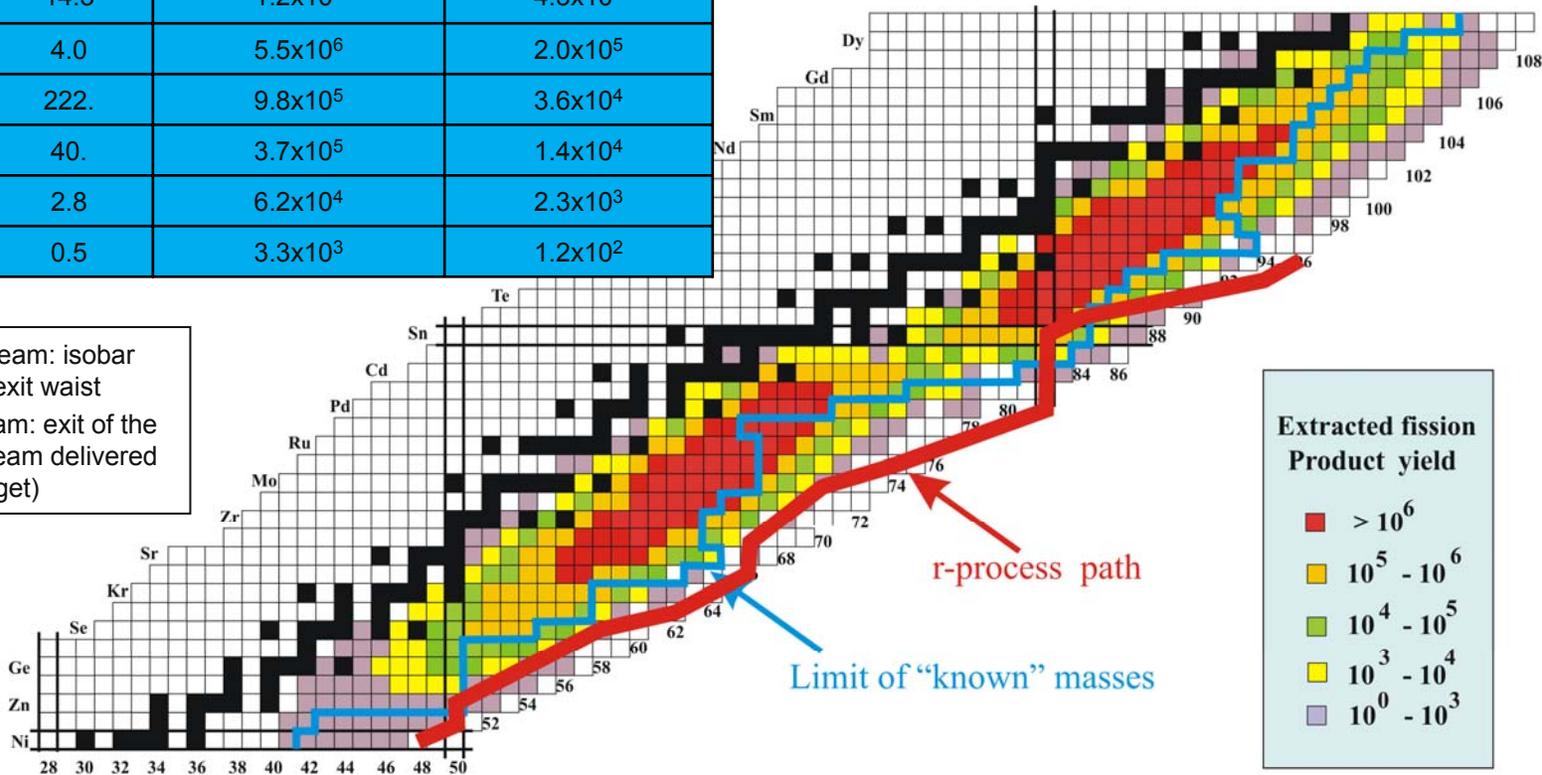
- The CARIBU project
- Charge breeder system
 - Stable sources, beamline, ECR source
- Charge breeding results
 - *Faraday cup problems*
 - *Background effect*
 - Current results with Cesium and Rubidium
- Future plans

The CARIBU project – CALifornium Rare Ion Breeder Upgrade

- In its final configuration, a 1.0 Ci ^{252}Cf fission source will provide radioactive species to be delivered to the ECR ion source for charge breeding

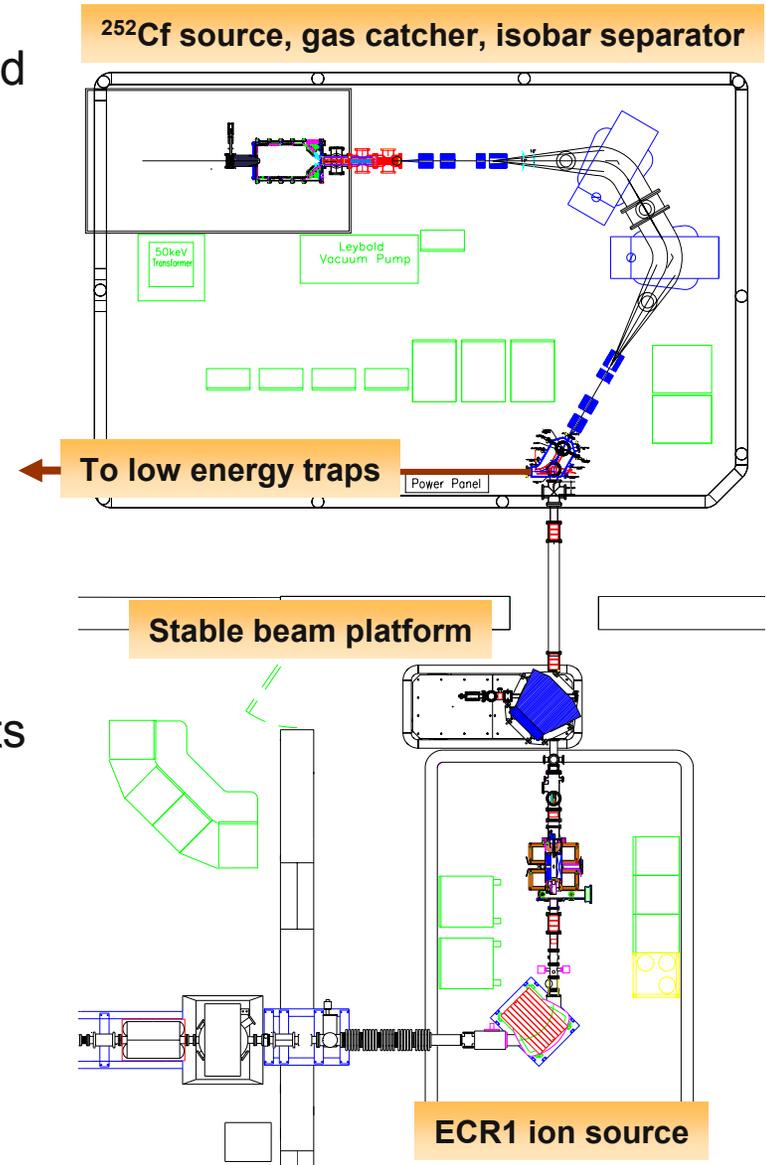
Isotope	Half-life (s)	Low-Energy Beam Yield (s^{-1})	Accelerated Beam Yield (s^{-1})
^{104}Zr	1.2	6.0×10^5	2.1×10^4
^{143}Ba	14.3	1.2×10^7	4.3×10^5
^{145}Ba	4.0	5.5×10^6	2.0×10^5
^{130}Sn	222.	9.8×10^5	3.6×10^4
^{132}Sn	40.	3.7×10^5	1.4×10^4
^{110}Mo	2.8	6.2×10^4	2.3×10^3
^{111}Mo	0.5	3.3×10^3	1.2×10^2

Low energy beam: isobar separator exit waist
 Accelerated beam: exit of the ATLAS linac (beam delivered to target)



The CARIBU project

- Fission products are collected and thermalized in a helium gas catcher
 - ~20% of all activity extracted as ions
 - Mean delay time <10 msec
 - Extraction is element independent
 - Provides cooled bunched beams for post acceleration
 - *Energy spread* <1 eV
 - *Emittance* $\sim 3 \pi \cdot \text{mm} \cdot \text{mrad}$
- High resolution mass analysis (1:20,000) limits the number of isobars in the analyzed beam
 - Reduces ECR source contamination
 - To achieve the required resolution, beam extraction must occur at ≥ 50 kV
 - Must maintain a voltage stability of ± 1 V



Transfer line and stable beam source

Electrostatic deflector

Einzel lens

Einzel lens

Einzel lens

ECRCB

Transfer line

- Three einzel lenses with emittance measurement station and weak beam profile and current monitors
- Image points of transfer line and stable beam source are matched

Stable beam sources

- Surface ionization
 - 1.0 eμA beams of Li, Na, Mg, K, Ca, Rb, Cs, Ba, Sr
- RF discharge source
 - 1-2 eμA beams of Ne, Ar, Kr, and Xe

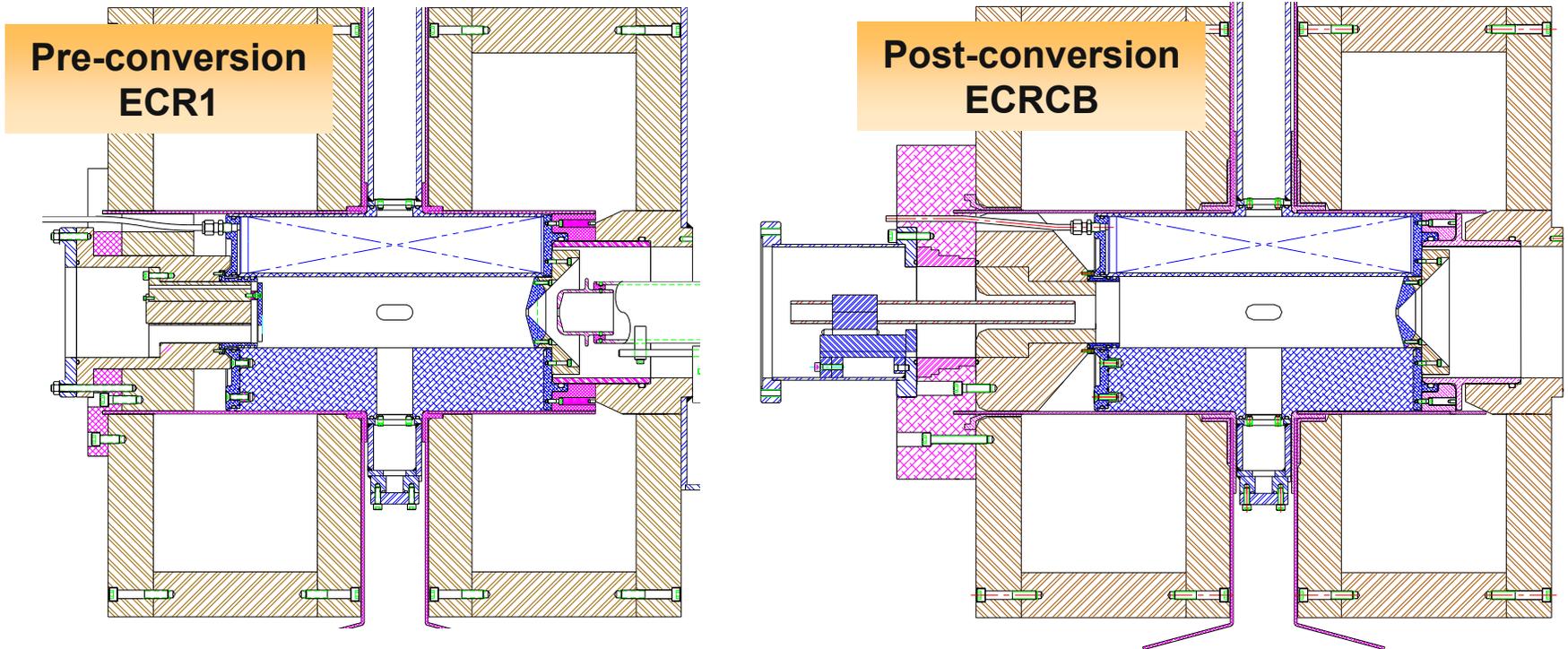
Stable beam source

Weak Beam Diagnostics

Intensity
Emittance

ECRCB

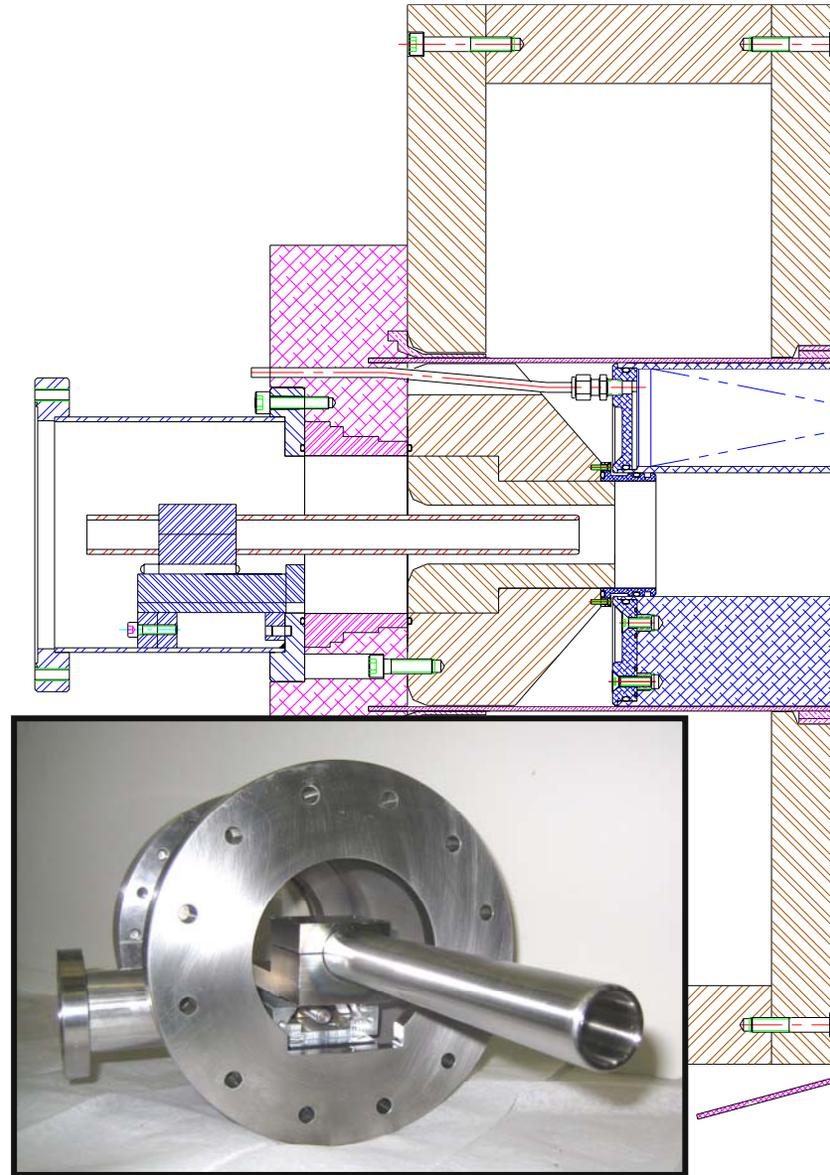
Source modifications for charge breeder operation



- Improved the high voltage isolation for 50 kV operation
- Modified the injection side of the source to accept low charge state beams
 - Removed the central iron plug to allow for transfer tube penetration
 - Moved the RF injection from an axial to a radial position
 - *Open hexapole allows radial RF injection*
 - *Provides more iron so that the magnetic field on injection side is symmetric*
 - Reshaped the remaining iron to improve B_{inj}

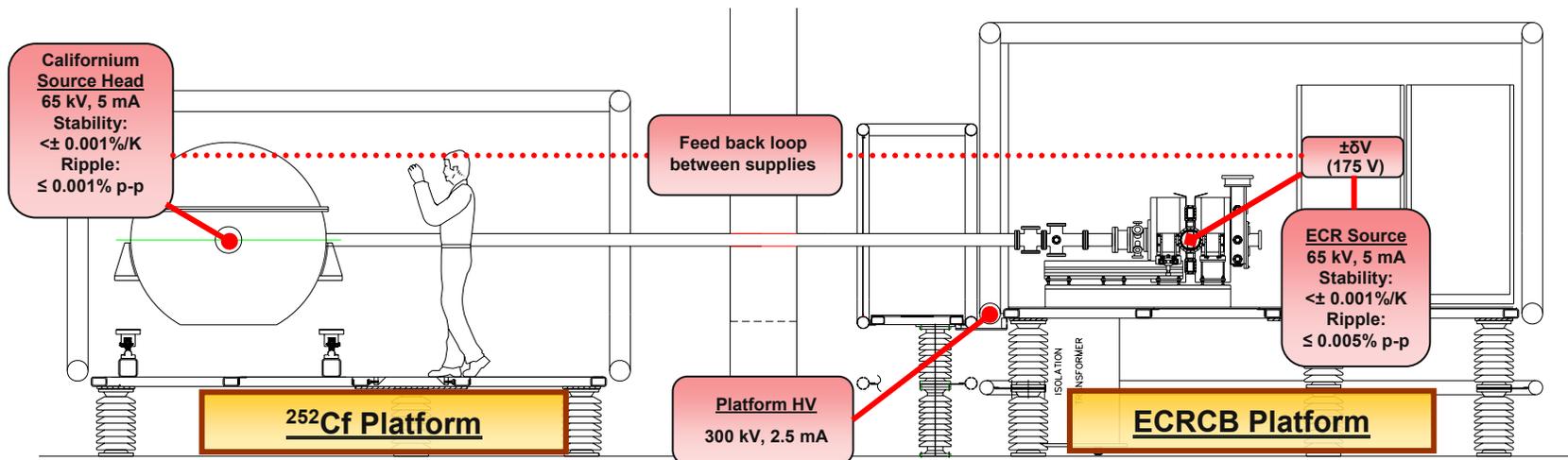
Injection side configuration

- Lexan insulator provides structure with an alumina liner exposed to vacuum
 - Base pressure in the ECR source and beamline is 2.0×10^{-8} Torr
 - *Source pressure increases to 1.5×10^{-7} with plasma on*
 - *Beamline pressure increases to 2.0×10^{-7} with plasma on*
- Movable transfer tube
 - 3.15 cm of travel
 - Originally placed just outside of the magnetic maximum
 - *Resulted in drain current of 4.0 mA at 50 Watts and unstable source operation*
 - Retracted position by 4.0 cm
 - *Drain current decreased to 0.3 mA and source operation stabilized*



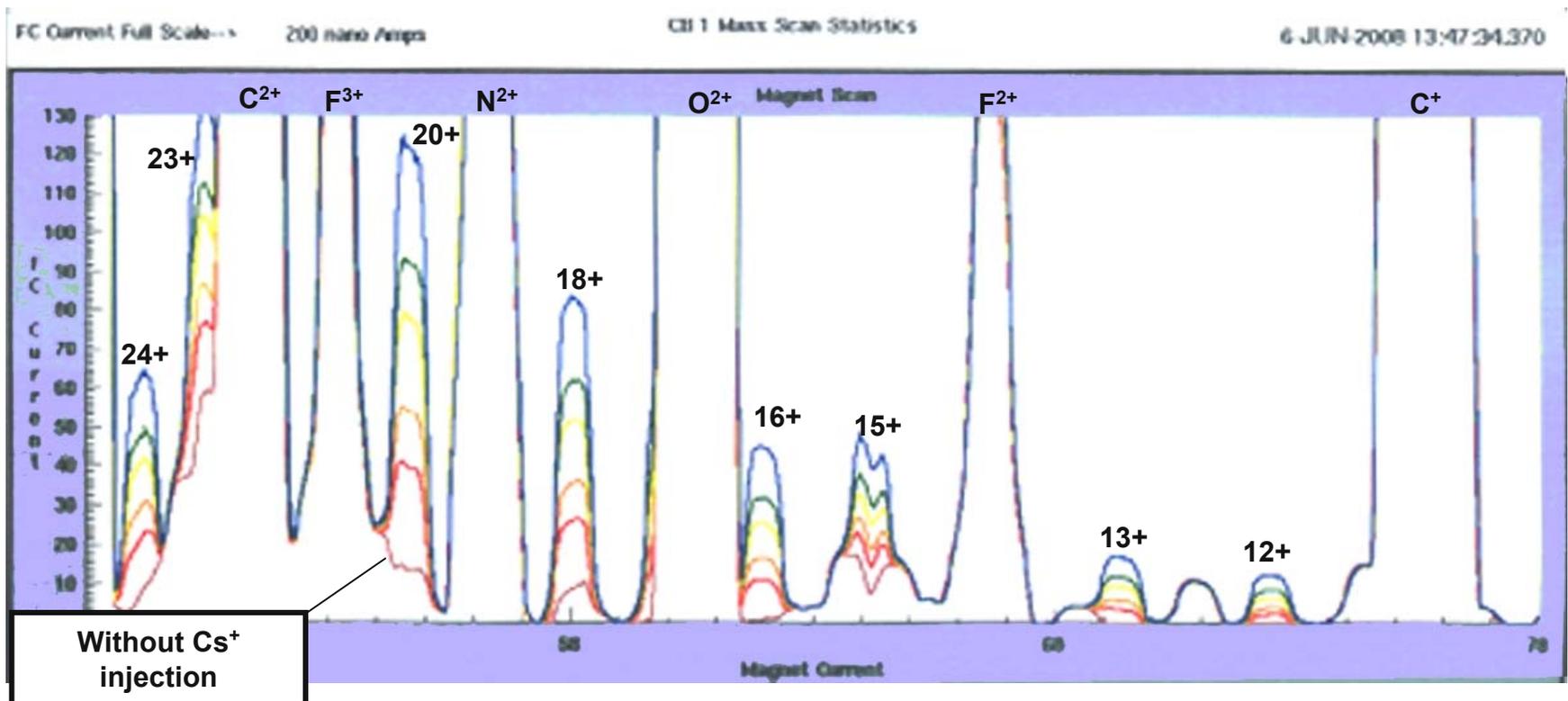
High voltage relationships and stability

- High voltage platforms will be energized by a single power supply (300 kV, 2.5 mA)
 - Beam pipe links the two platforms together ensuring common potential
- Source heads will be energized by separate high voltage power supplies (65 kV, 5 mA)
 - Flexibility to operate in “Stand Alone” mode → low energy traps, source development
 - Decouples any influence of ECR plasma fluctuations on the californium bias voltage
 - Ensures ± 1.0 V voltage stability for isobar separator
- Additional ± 175 V power supply (“tweaker”) is in series with the ECRCB
- Feed back controller ensures voltage match between the Cf and ECRCB source heads
 - Adjusts the ‘tweaker’ supply to match the source potentials (nominally 50 kV)
 - Then an additional voltage is summed in to optimize the 1+ ion capture



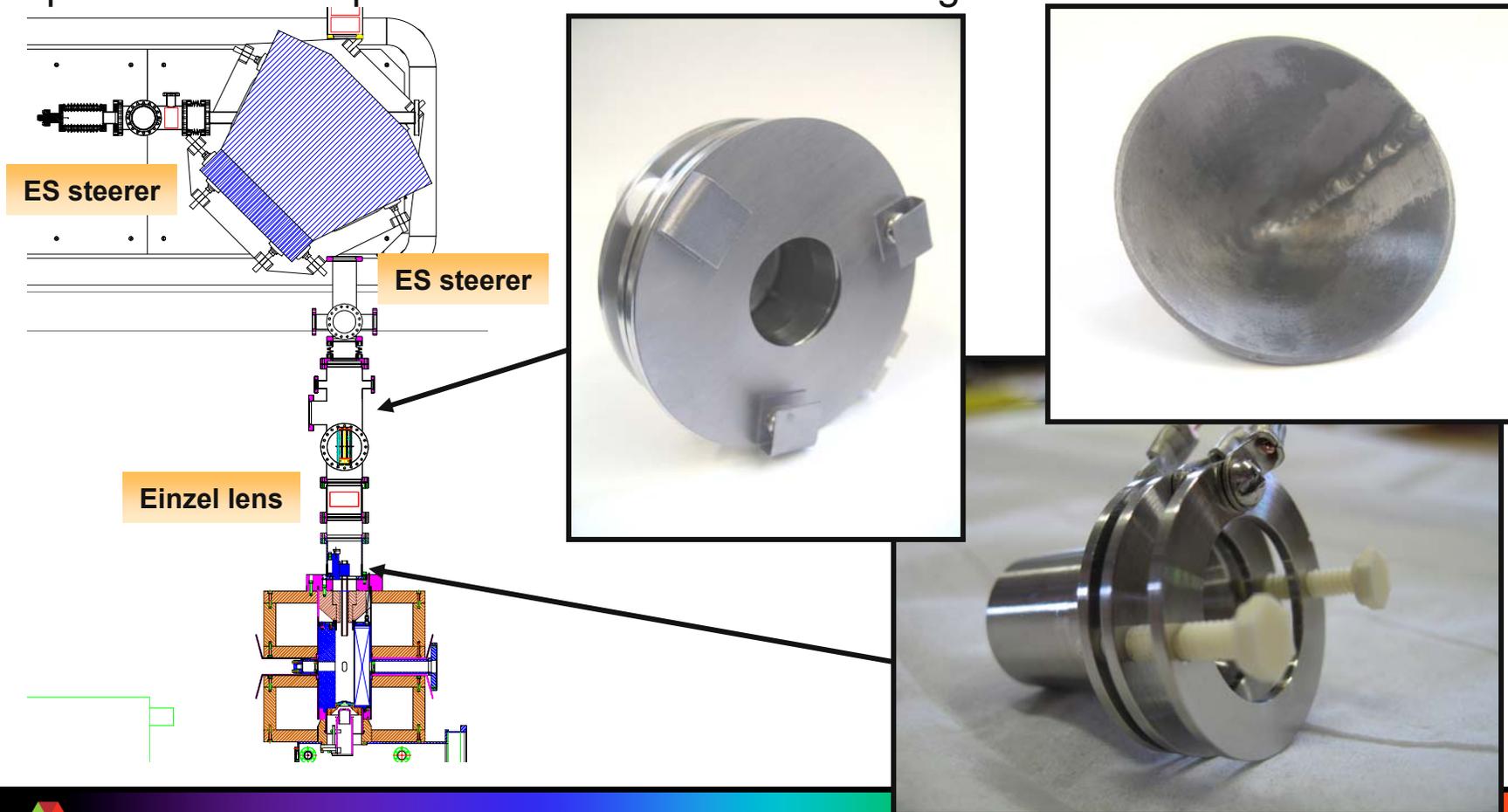
Cesium charge breeding spectrum

- Achieved first charge bred beam in May 2008
- Mass spectrum of the ECRCB output with and without Cs⁺ injection
 - Background beam, without Cs⁺ injection, is shown in brown
 - Other traces represent varying levels of charge bred cesium as a function of the Cs⁺ input intensity



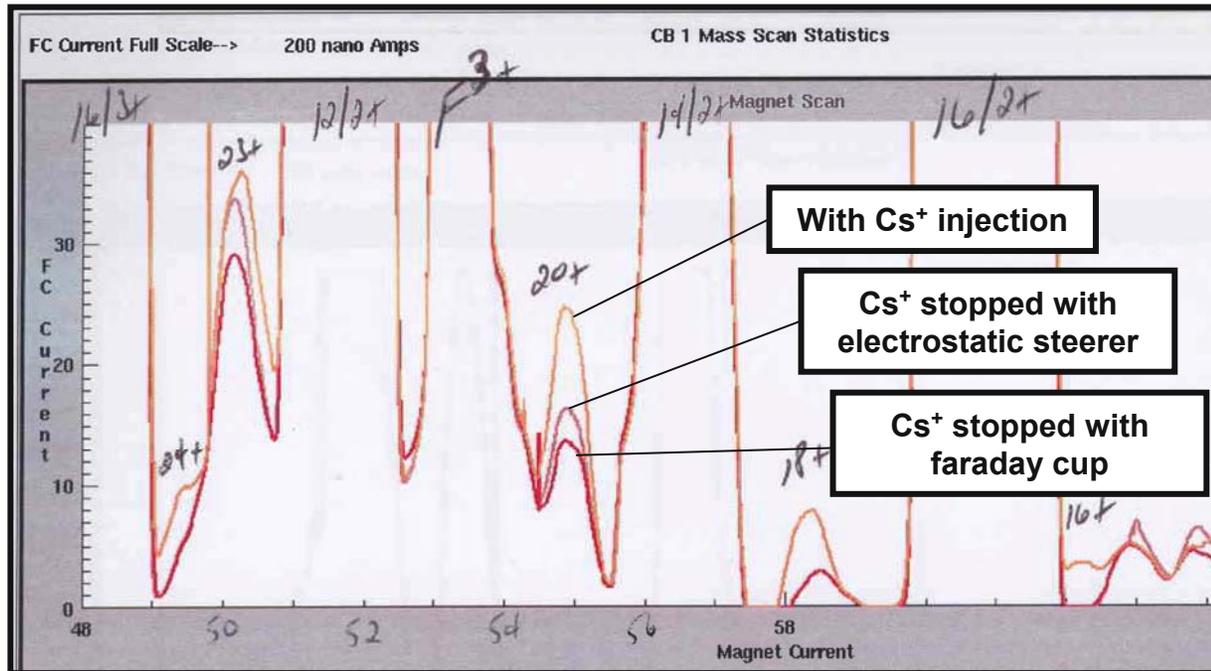
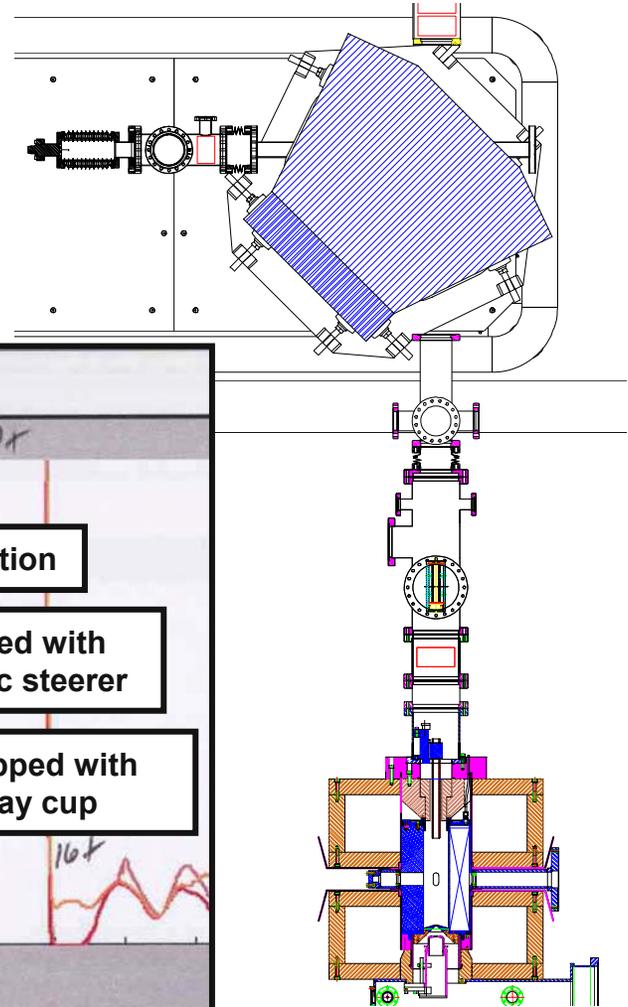
Beam current measurement - 1+

- Obtained unrealistic charge breeding efficiencies – 9→12%
- Constructed a new faraday cup which was placed at front of transfer tube
- Problem traced to an insulating layer on the tantalum charge collector
- Replaced tantalum piece with a stainless steel charge collector



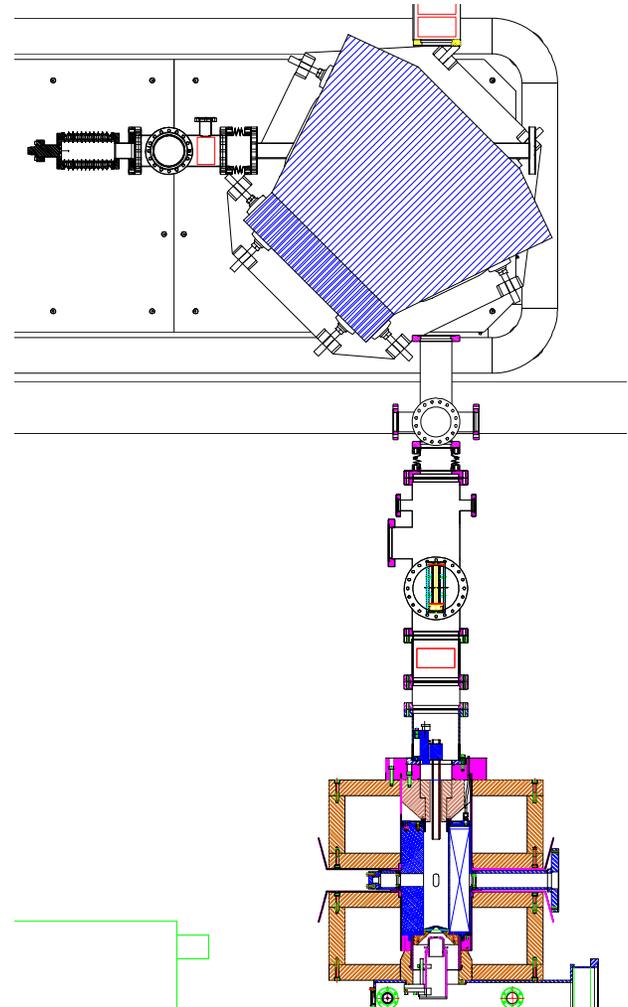
Background measurement

- Observed a difference in background level for some of the Cs peaks which was dependent upon which method was used to stop the 1+ beam from entering the ECR source



Background measurement

- Observed a difference in background level for some of the Cs peaks which was dependent upon which method was used to stop the 1+ beam from entering the ECR source
- Difference in background level is due to outgassing in the 1+ analyzing magnet generated by the n+ beam extracted from the injection side of the ECR source
 - $^{133}\text{Cs}^{20+}$ very similar m/q as $^{40}\text{Ar}^{6+}$
 - $^{133}\text{Cs}^{23+}$ very similar m/q as $^{40}\text{Ar}^{7+}$
 - $^{133}\text{Cs}^{16+,18+,24+}$ do not exhibit this behavior
- For $^{133}\text{Cs}^{20+}$, with the same incoming Cs⁺ intensity, the effect is clear
 - Saturating the steerer
 - *2.6% efficiency*
 - Putting the faraday cup in
 - *6.5% efficiency*



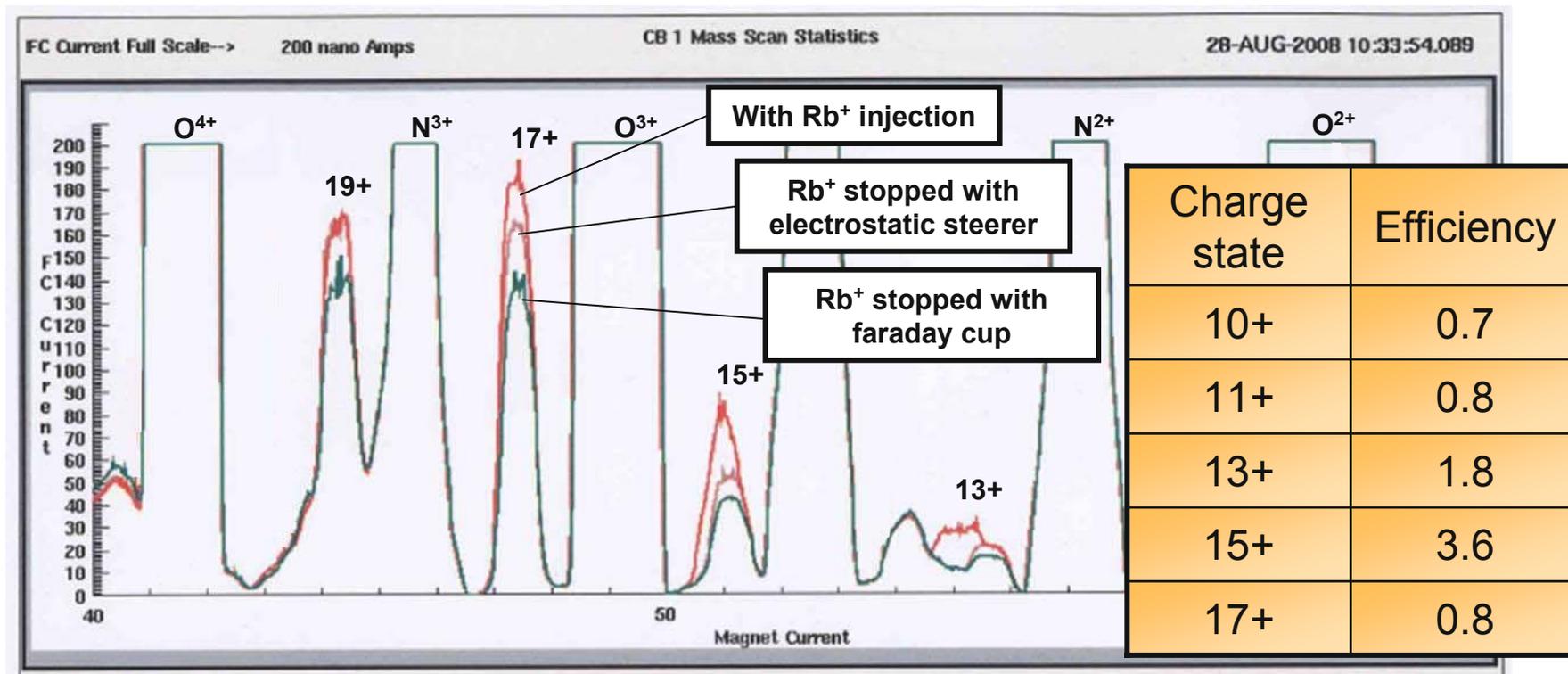
Results of charge bred cesium

- Optimized on $^{133}\text{Cs}^{20+}$ using oxygen support gas and 250 W at 10.44 GHz
- Cs^+ beam current was 62 enA
- Also tried two-frequency heating
 - Power levels set so that total power level matched single frequency case
 - 175 W at 10.44 GHz
 - 75 W at 12.27 GHz
- Insulators on surface ionization source breaking down
 - Poor optics conditions

Charge state	Single Frequency Efficiency	Two Frequency Efficiency
16+	0.9	1.4
18+	1.0	1.5
20+	2.4	2.9
23+	0.5	1.1

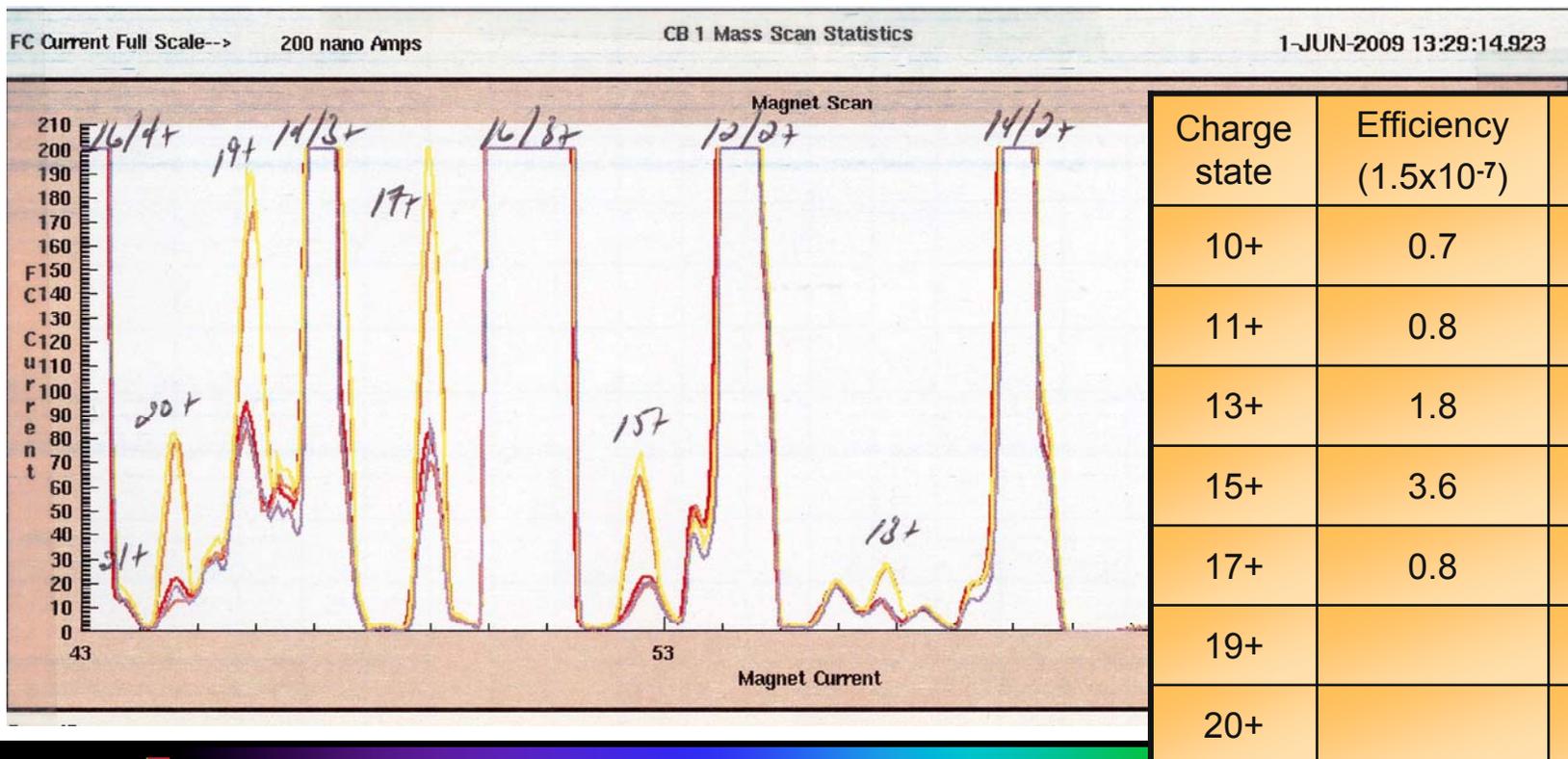
Charge bred rubidium beam (August 2008)

- Mass spectrum of ECR ion source output with and without Rb⁺ injection
 - Rebuilt surface ionization source
 - *Cleaned insulators and realigned elements*
 - Optimized on ⁸⁵Rb¹⁵⁺ with oxygen support gas and 270 W at 10.44 GHz
 - Source operating pressure 1.5x10⁻⁷ Torr



Results of charge bred rubidium (June 2009)

- No work with the ECR charge breeder since September 2008 while other aspects of the CARIBU program were completed
 - Source was under vacuum the entire time and has resulted in the operating pressure improving from 1.5×10^{-7} to 7.5×10^{-8} Torr
 - Peak of charge state distribution has shifted from 15+ to 17+
 - Breeding efficiency has improved



“Pepper Pot” emittance system on 2Q-LEBT

- Mask has 100, 100 μm pinholes, 3 x 3 mm spacing, working area: 27 x 27 mm
- Behind mask is CsI crystal (80 mm diameter) which is viewed by CCD camera
- Beam energy of 75 keV/q and current density of $<1.0 \text{ e}\mu\text{A}/\text{cm}^2$ with Bi beam

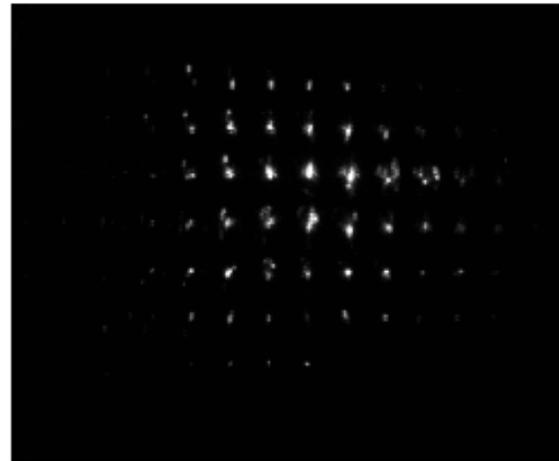
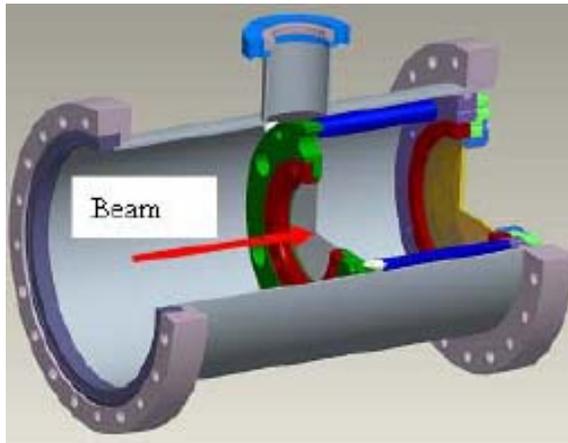
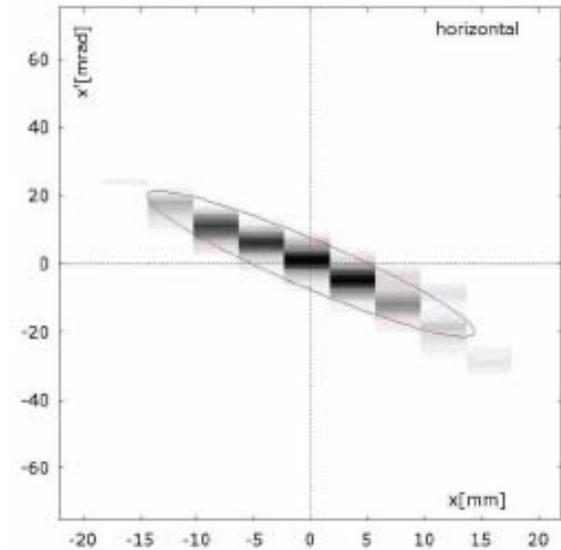


Figure 6: Pepper pot image of $^{129}\text{Xe}^{14+}$ ion beam.



RMS emittance: 27.531 mm-mrad
Norm. RMS emittance: 0.090441 mm-mrad
Alpha: 2.615
Beta: 1.884 mm/mrad
Gamma: 4.16 mrad/mm

Figure 7: Horizontal phase space plot of the $^{129}\text{Xe}^{14+}$ ion beam.

TUPAS003

Proceedings of PAC07, Albuquerque, New Mexico, USA

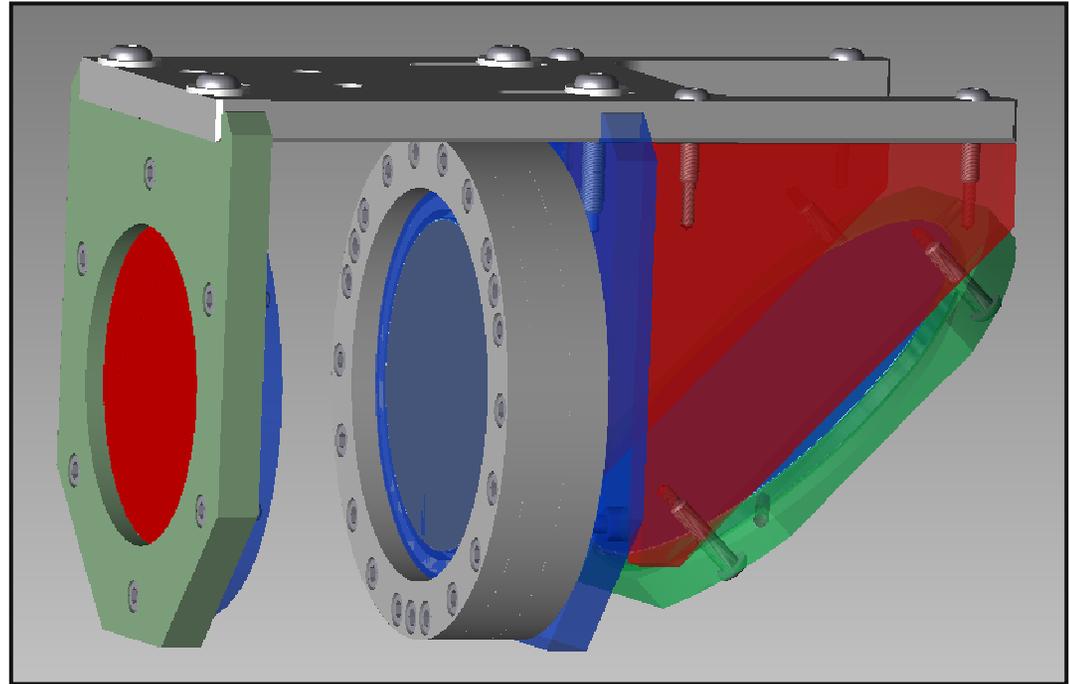
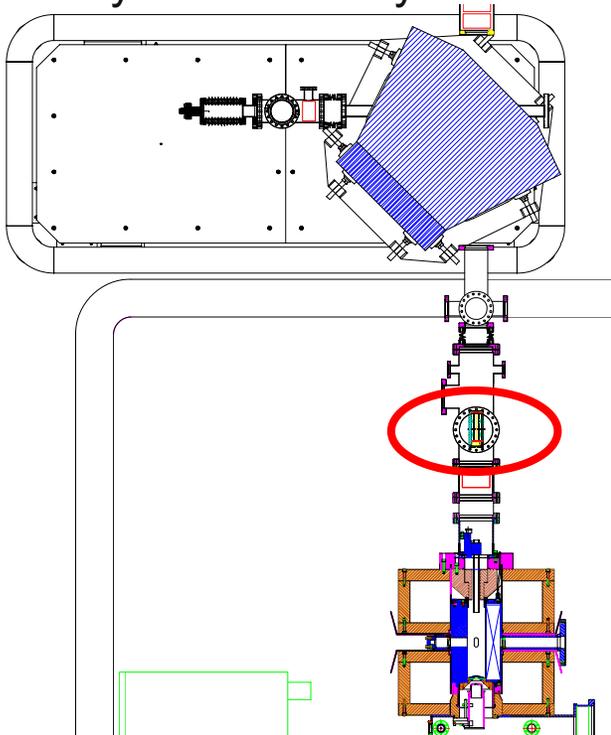
EXPERIMENTAL RESULTS ON MULTI-CHARGE-STATE LEBT APPROACH*

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“Pepper Pot” emittance system for ECR charge breeder

- Mask has 20 μm laser drilled holes, 0.5 x 0.5 mm spacing, 40 mm diameter
- Behind the mask is a CsI crystal (40 mm diameter)
 - Scintillator tested with a 300 nA, 10 kV beam
- Distance between the mask and the scintillator is variable
- Improved sensitivity possible with the addition of a micro channel plate/phosphor
- System is ready for installation



Future plans for the charge breeder

- Continue with beam development using rubidium source
 - Multiple frequency heating
- Install RF discharge source to develop source performance with gases
- Replace stainless steel transfer tube with one made of soft iron
 - Improves magnetic field on injection side of ECR source
- Improve pumping at injection region
 - Have seen evidence that a lower pressure will improve the efficiency
 - Modified the injection chamber to accept another turbo pump
- Reduce outgassing
 - Bake out the 1+ transport line
 - Beamline collimators to inhibit backstreaming into ECR source
 - Cooling baffles inside of 1+ analyzing magnet
- Pursue cleaning of plasma chamber using high pressure rinsing
 - Background is not yet a critical issue, but will become more important as CARIBU comes on line
- Hot liner in ECR plasma chamber for wall recycling